Remarks

The Examiner has objected to the oath as being defective. A new corrected oath is provided herein.

The Examiner has stated that the request to correct the inventorship is deficient. The request to correct the inventorship has been corrected and is enclosed herein.

The Examiner has rejected claims 1-14 under 35 USC 102(f) based on improper inventorship. With the inventorship properly corrected as enclosed herein, Applicants believe that claims 1-14 are now in condition of allowance. Applicants respectfully request reconsideration.

Respectfully submitted,

Chen et al.

Date:

Bv:

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Agent for Applicants

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